

# Standardizing MEMS Testing Equipment:

A path to efficiency and  
scalability

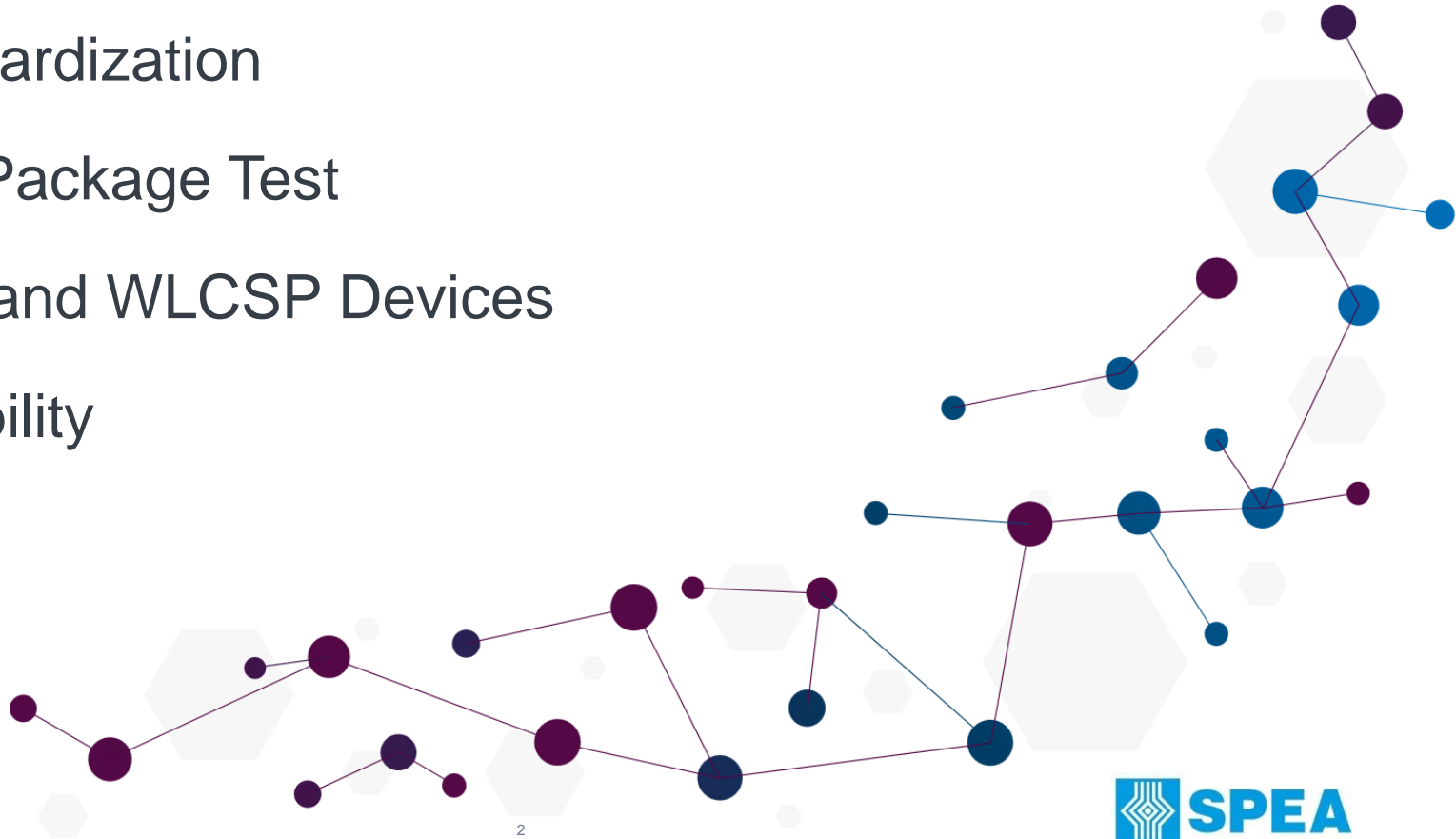
February 13<sup>th</sup>, 2025



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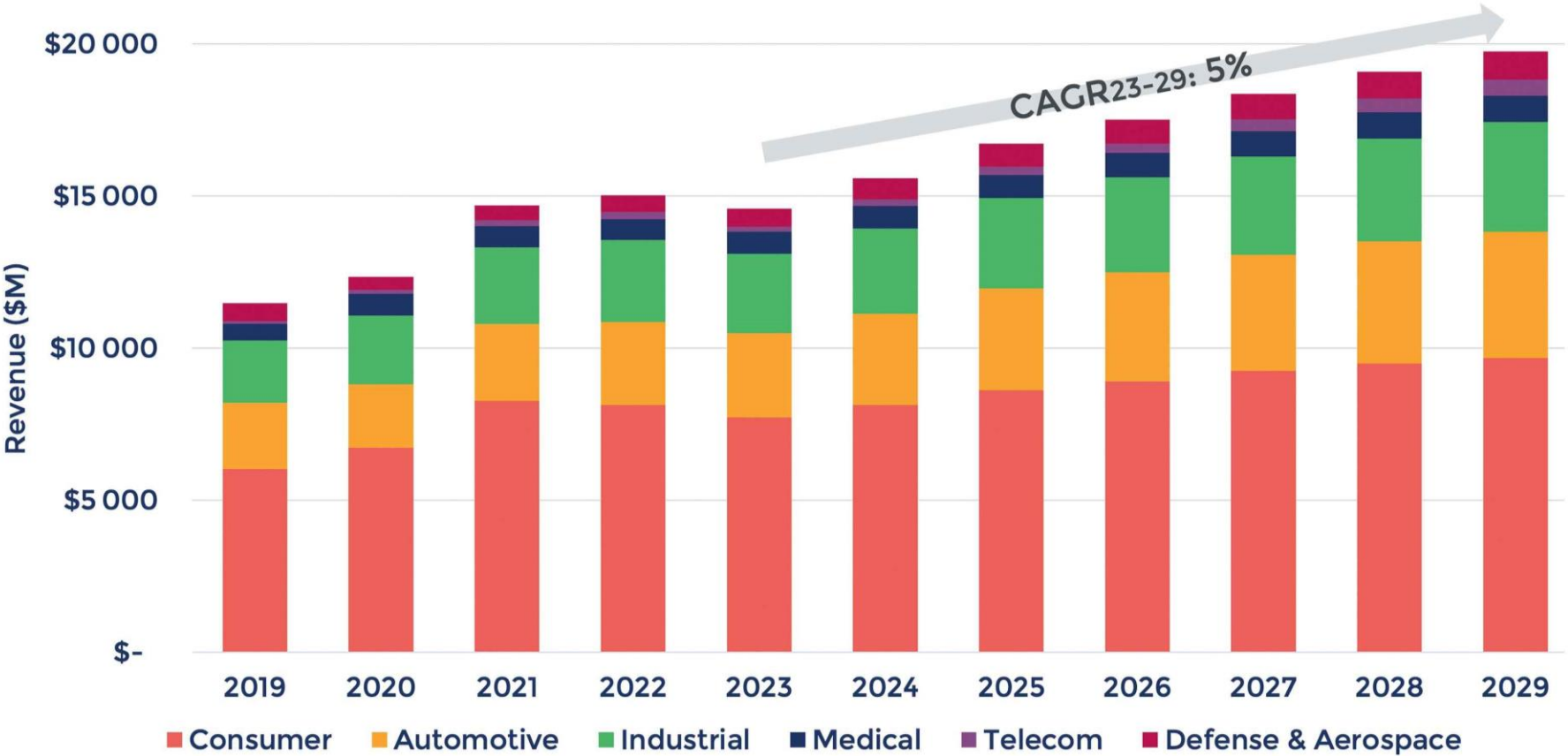
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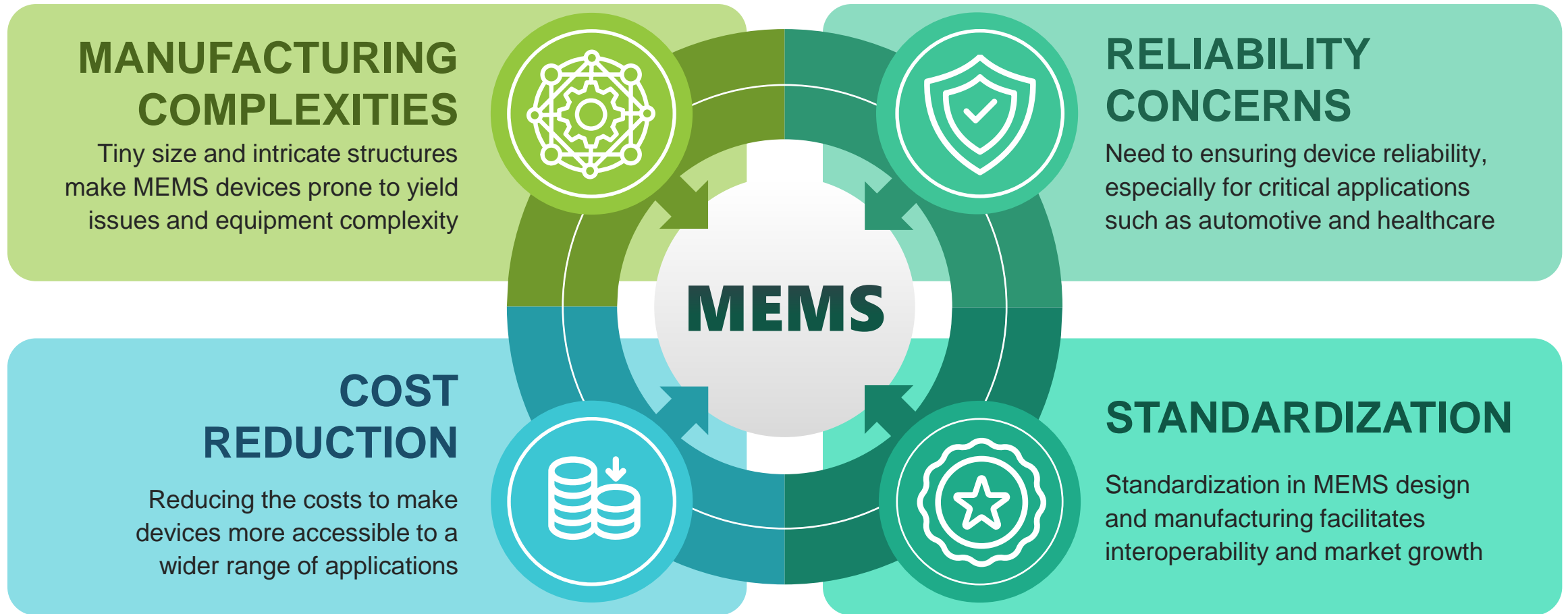
# MEMS Market Growth

After a difficult 2023, MEMS market is expected to reach **\$20 billion** by 2029, growing at a CAGR of 5%



Source: Status of the MEMS Industry report, Yole Intelligence, 2024

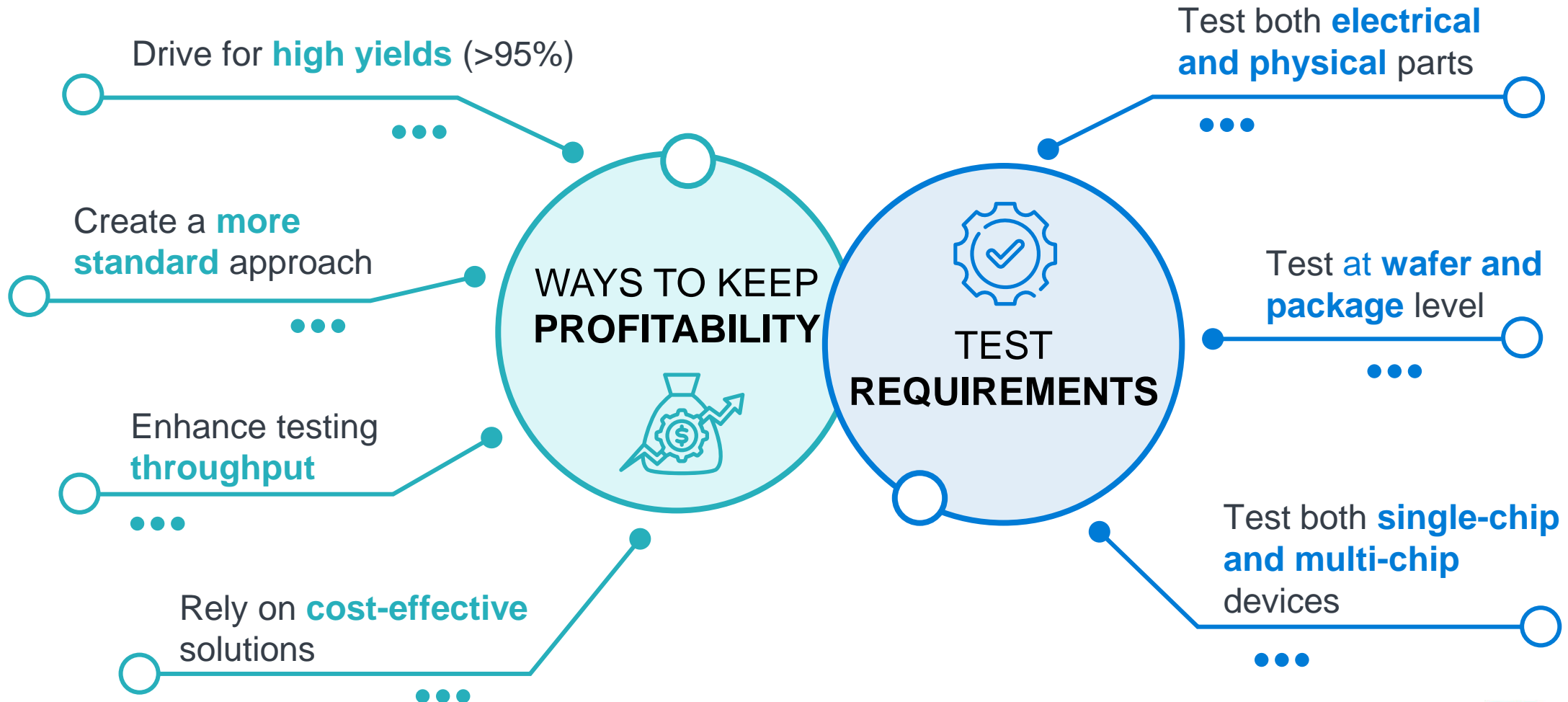
# Challenges in the MEMS Industry



Test equipment has an impact on all these aspects and can help face these challenges.

# MEMS Testing Scenario

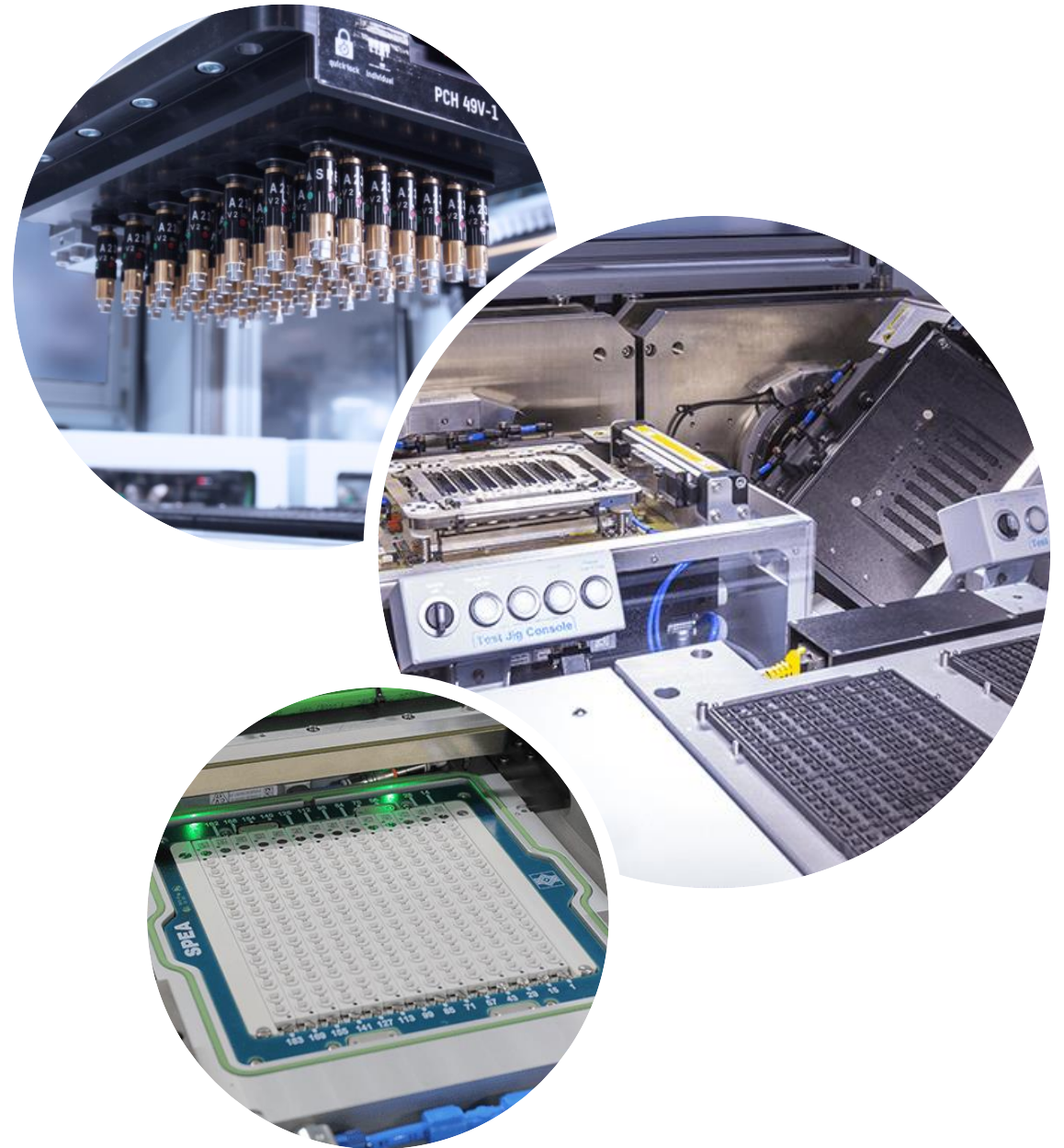
Test and calibration represent a major cost contributor for MEMS devices, and problems related to calibration and accuracy remain a major challenge that may hamper the growth of the market



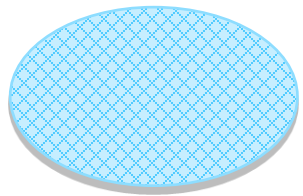
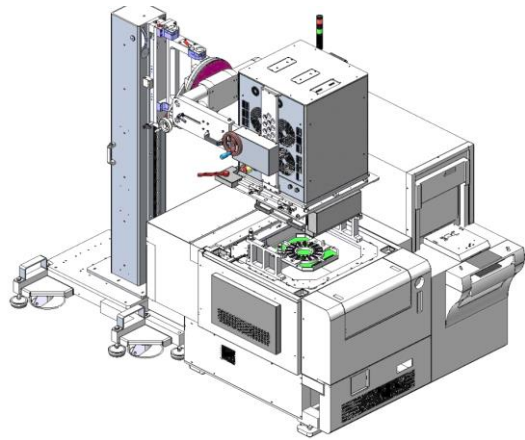


# MEMS ATE Standardization

- In the past, test equipment for MEMS has been **strongly application-dependent** and scarcely reusable for different devices
- However, having a completely different machine for each different product is becoming **less and less efficient**, as the number of devices increases exponentially
- More and more companies are recognizing the need for a **testing and handling solution that is suitable for the requirements of high-volume production lines, scalable, and convertible** for different application technologies.

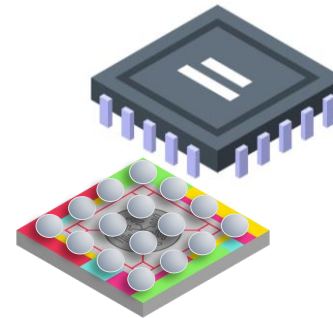
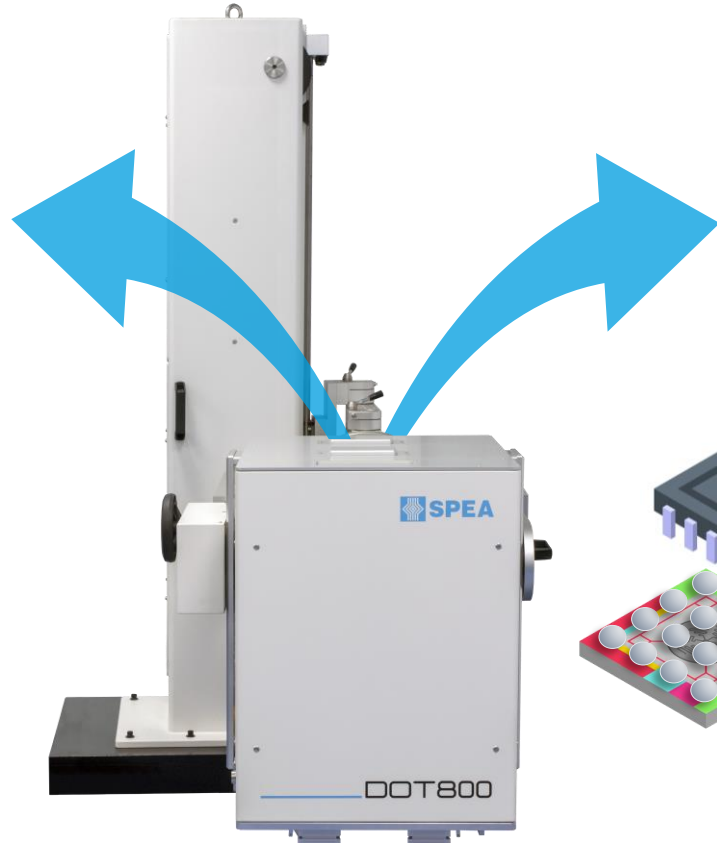


# The same test platform should be suitable for both wafer-level and package test of MEMS and sensors



## Wafer-Level Test

With Tester + Prober



## Package Test

With MEMS Test Cell

# MEMS Testing at Wafer Level

## Combination of electrical and non-electrical measurements for early failure detection

Real-working conditions (e.g. acceleration applied to the device) are obtained by electro-static stimulation, making the device mass moving from its reference idle position. The device frequency answer is then measured.

- **High Multisite**
- **fF Capacitance measurements**, with 2.2MHz bandwidth and DC bias -10V to 20V
- **pA Current measurements**
- **μV Voltage measurements**
- **1000kOhm /10pF impedance measurements**
- **mΩ/GΩ Resistance measurements (4-wire configuration)**





# MEMS Testing at Package Level | Standard and WLCSP Packages

With a field setup adjustment, the same machine can be used for testing both standard packages and wafer-level packages. And it is ready to embrace tomorrow's technologies.

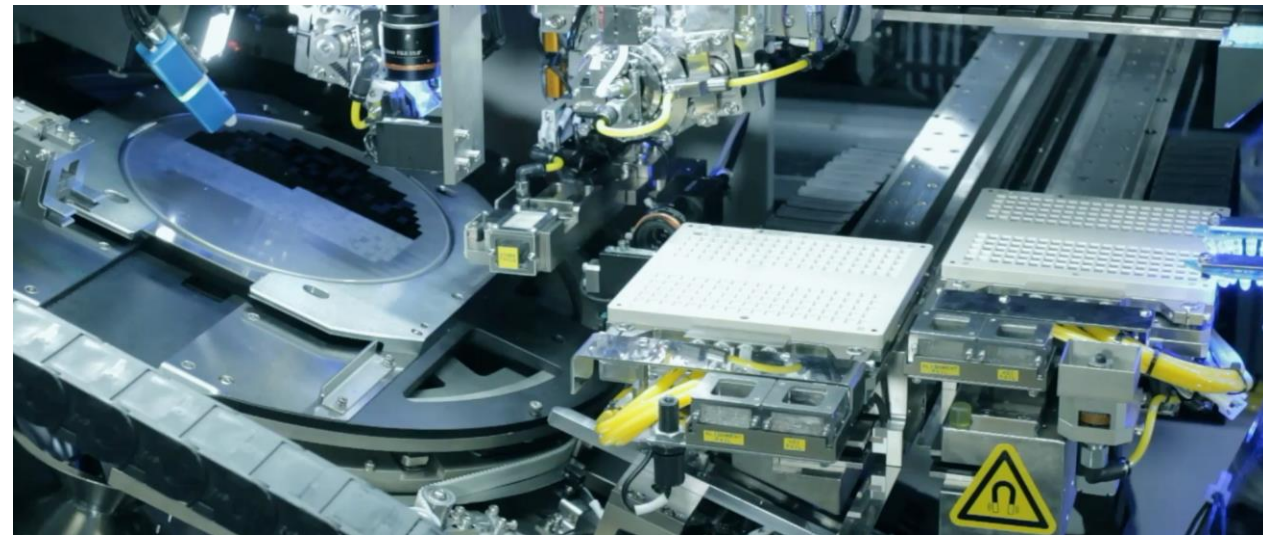
## Standard package test

Example of tray-to-tray handling and testing of three-axial accelerometers

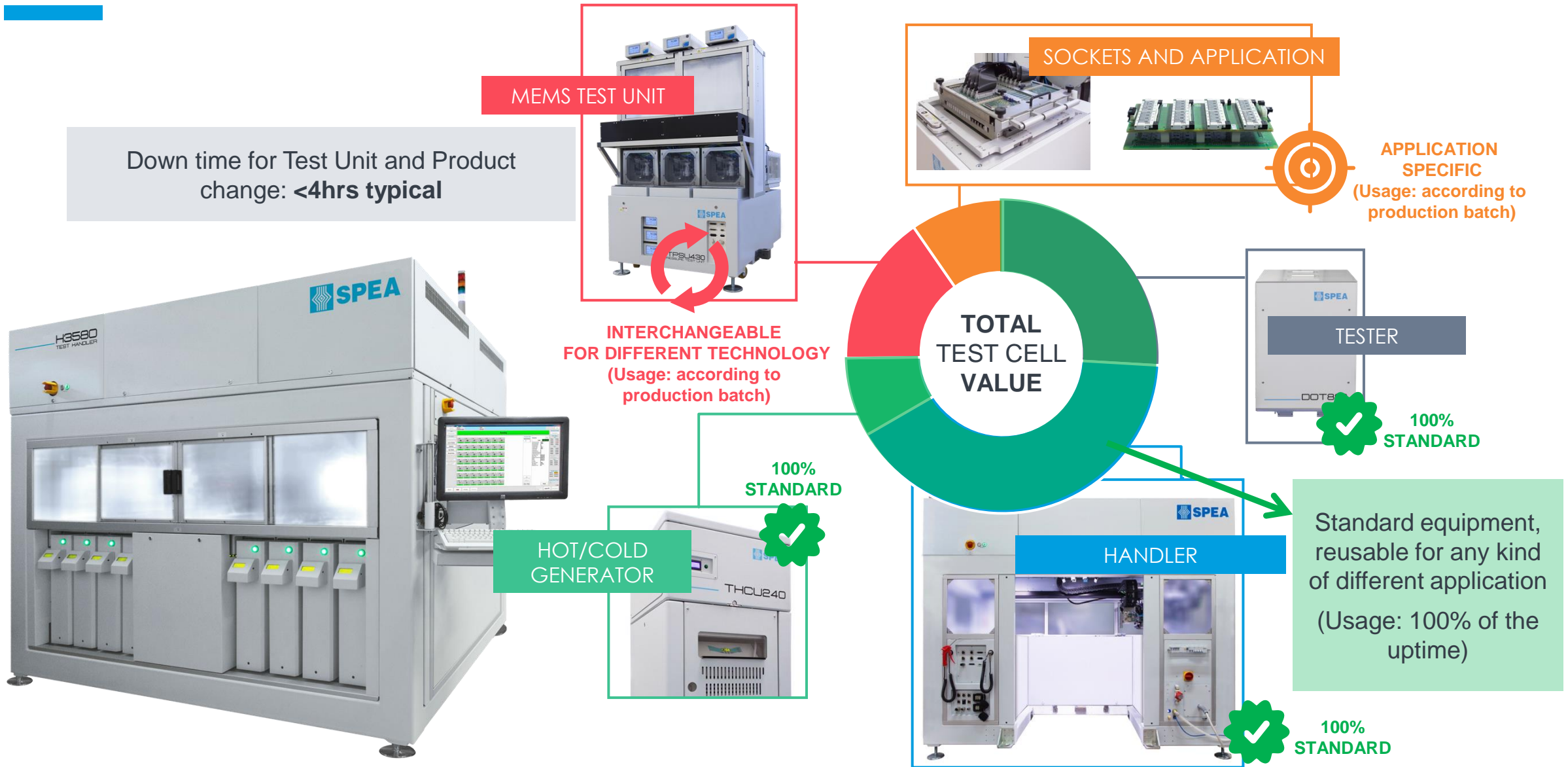


## WLCSP package test

Example of wafer-to-reel handling and testing of MEMS pressure sensors



# Standard ATE Architecture for MEMS Package Test



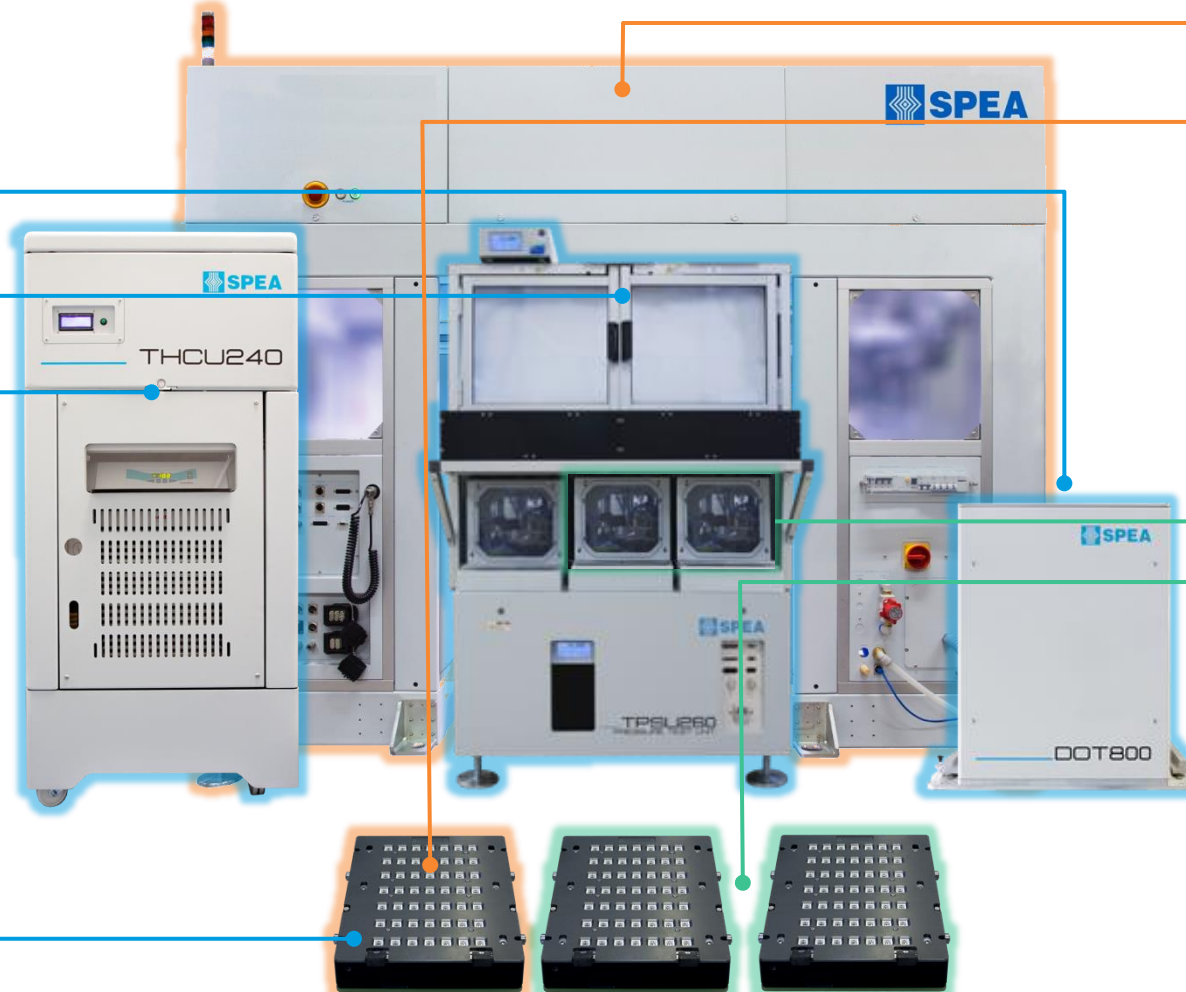
# Equipment Scalability

**Example: Pressure Sensor Test Cell.** The same equipment was expanded with additional modules for engineering, mid-volume and mass-production use.

STEP 1

## ENGINEERING

- Tester
- Pressure Test Unit with single Test Chamber
- Tri-Temp conditioning unit
- Contacting unit for 7 sites



STEP 2

## MID-VOLUME

- + Pick&Place Handler
- + Contacting unit for 49x multi-site

STEP 3

## MASS PRODUCTION

- + 2 Test Chambers
- + Contacting units for additional 98 sites



# Test Units for the main MEMS technologies



## INERTIAL

Low g accelerometers  
Gyroscopes  
High G sensors  
6-DOF sensors



## ENVIRONMENTAL

Barometric sensors  
Humidity sensors  
Temperature sensors  
Gas sensors



## PRESSURE

Absolute & Differential pressure sensors  
TPMS  
Force sensors  
Medium & high pressure sensors



## LIGHT

Proximity sensors  
Time-of-flight sensors  
Ranging sensors  
UV sensors  
IR sensors  
Gesture sensors



## MAGNETIC

Linear sensors  
Angular sensors  
Speed sensors

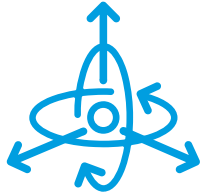


## ACOUSTIC

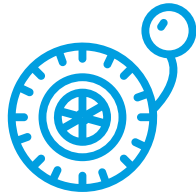
Microphones  
Speakers



# CASE STUDIES



## 1. Inertial MEMS

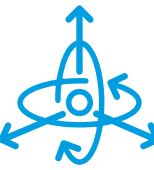


## 2. Pressure Sensors



## 3. Magnetic Sensors

# Case Study 1 Inertial MEMS

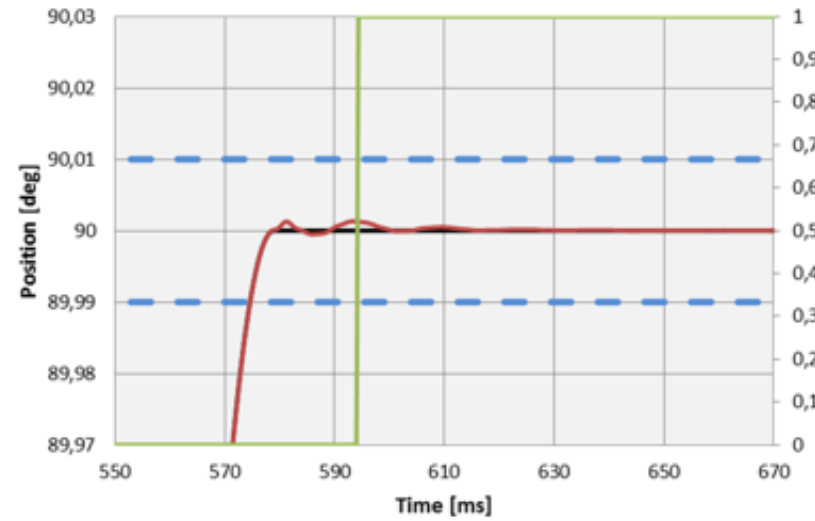


## HIGHLIGHTS

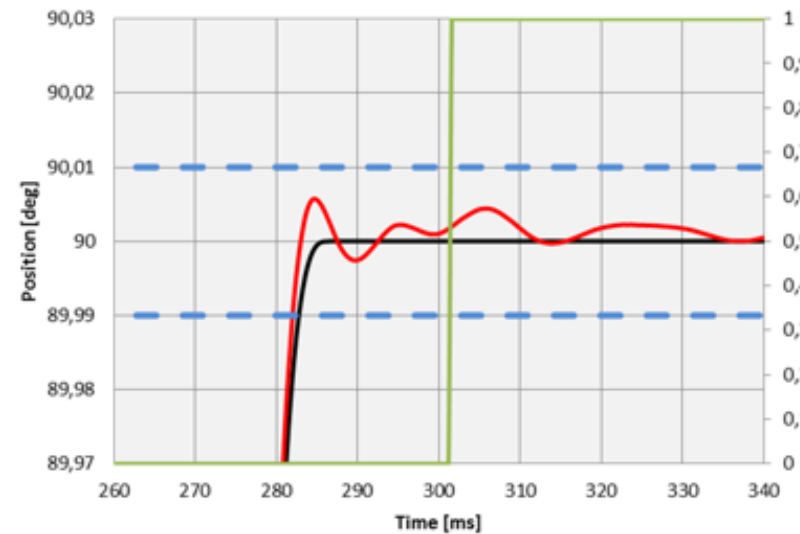
- 140 sites tested in parallel
- Double rate table stimulus in a single handler
- Same setup is suitable for accelerometer and gyro test
- High rate accuracy: no drift, excellent stability, high torsion stiffness



### Twist positioning 90°



### Tilt positioning 90°



## ACCELEROMETER TEST

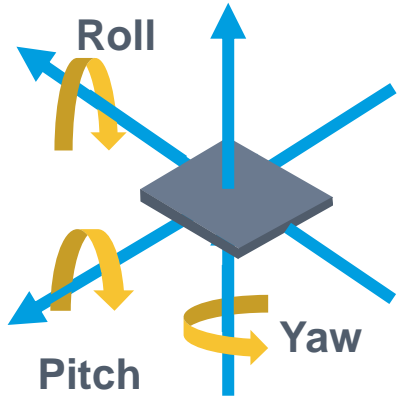
The Rate Table operates with high precision and accuracy in angular movements along the two axes.

Performances are guaranteed along angular stroke with excellent rate stability and position accuracy

- Precision  $\leq 0.01$  deg
- Accuracy  $\leq 0.01$  deg

- Theoretical position [deg]
- Real position [deg]
- In-window trigger

# Gyroscope Testing Details



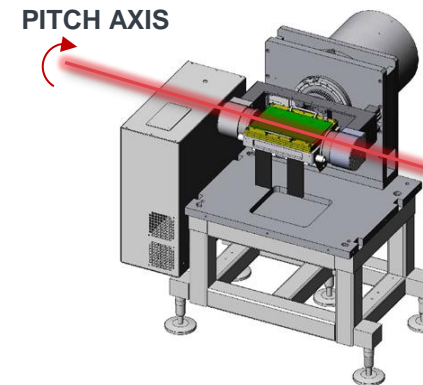
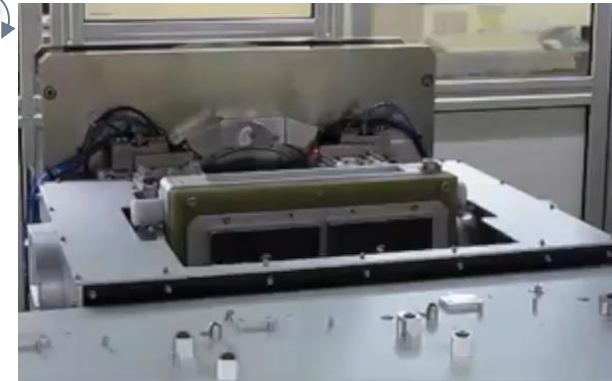
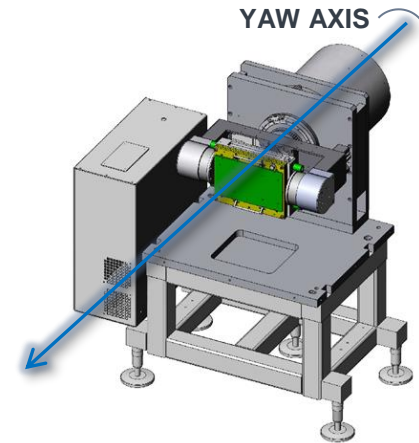
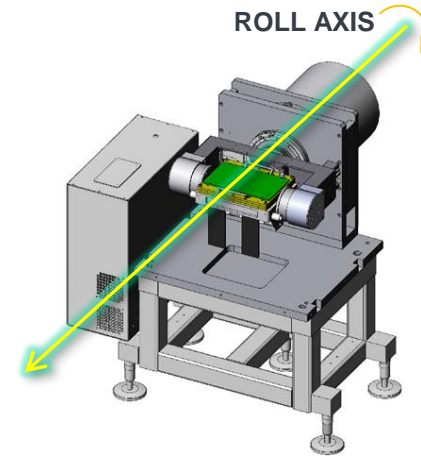
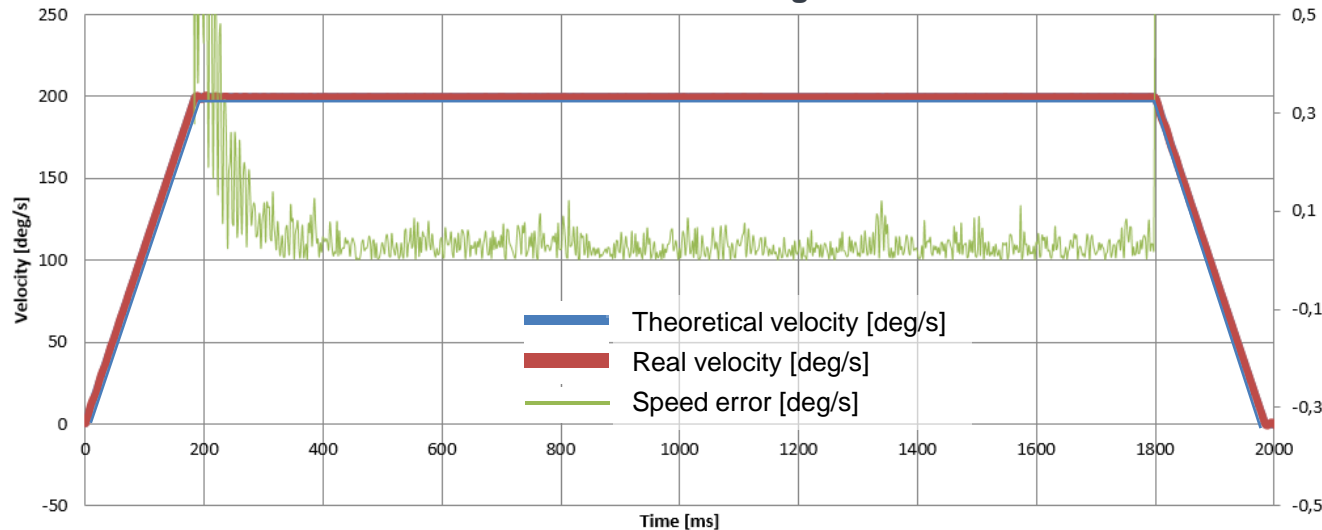
The Rate Table operates with constant angular speed during gyroscope test, with a very limited speed error.

Speed test, start and stop position are easily configurable.

Triggers are available for synchronization.

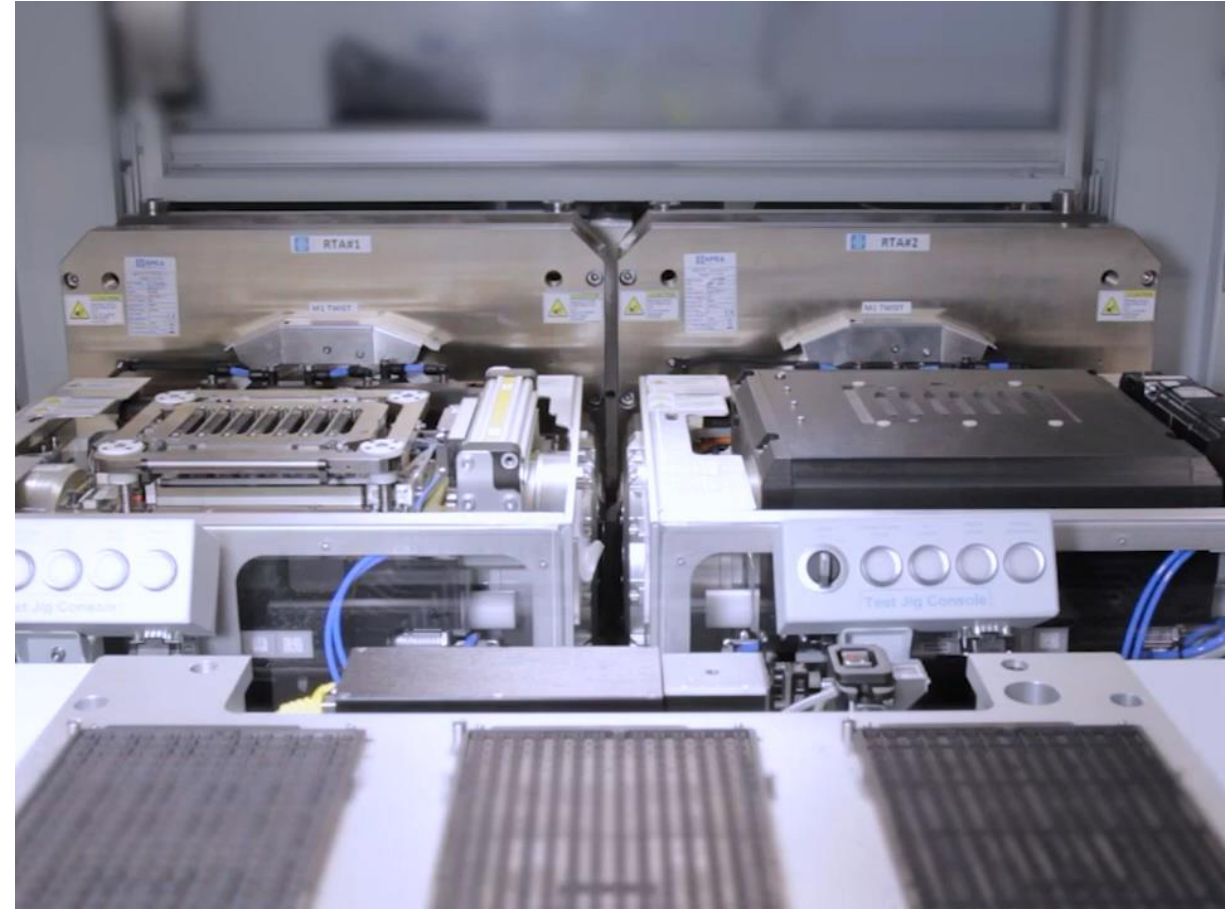
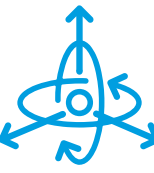
- Speed error  $\leq 0.1$  deg/s

Twist constant profile @ 200 deg/s  
Stroke 0 ÷ 360 deg





# Inertial MEMS Testing Operation



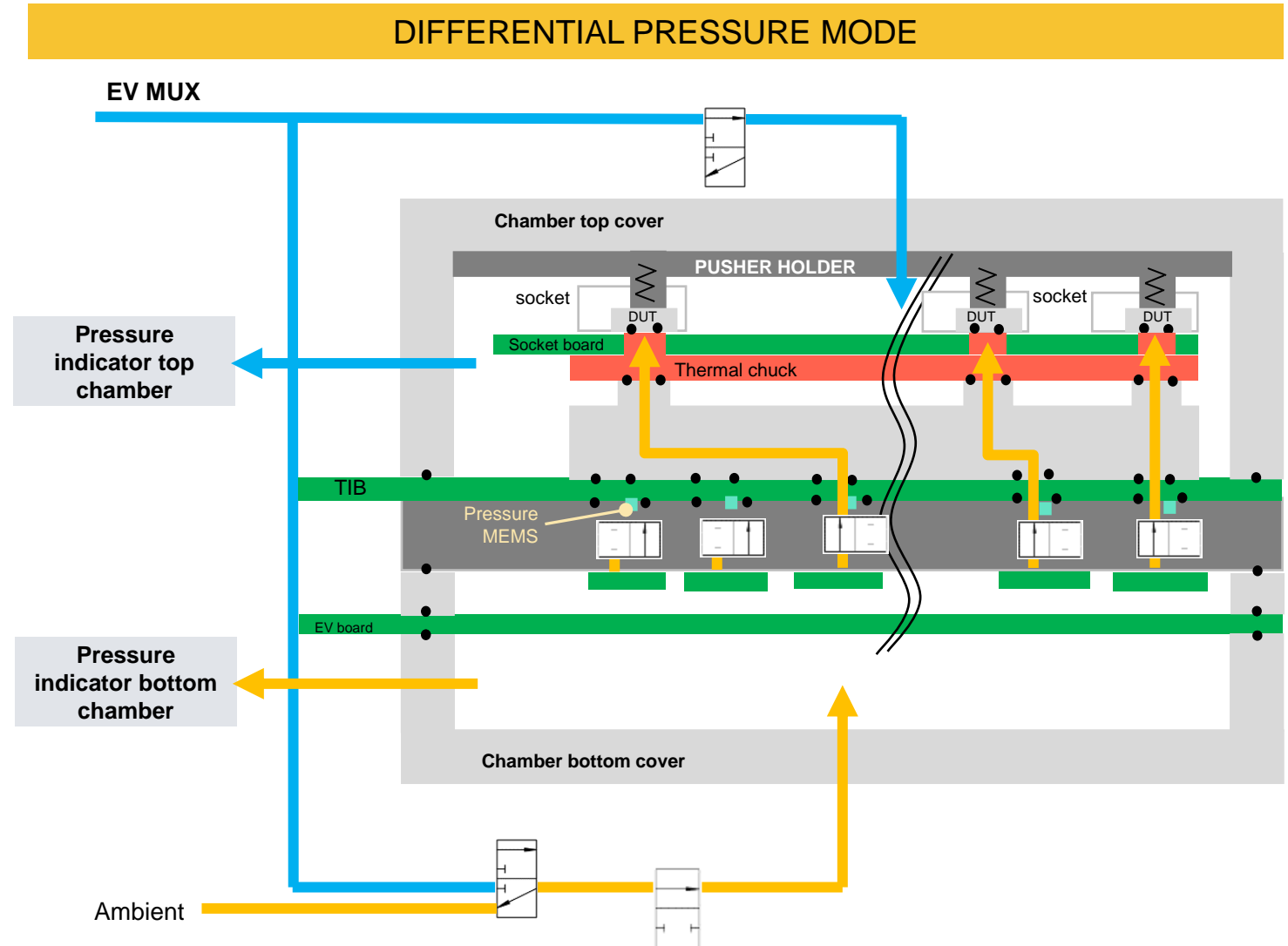


# Case Study 2 Pressure sensors



## HIGHLIGHTS

- 392 sites tested in parallel
- Absolute and differential pressure stimulus
- Up to 3 independent test chambers
- Multiplexed tanks to speed up set point change and settling time
- Absolute pressure ranges from 0.03 to 7.05 MPa (0.3 to 70.5 barA)
- Differential pressure range: -0.07 to 0.4 MPa (-0.7 to 4 bar)

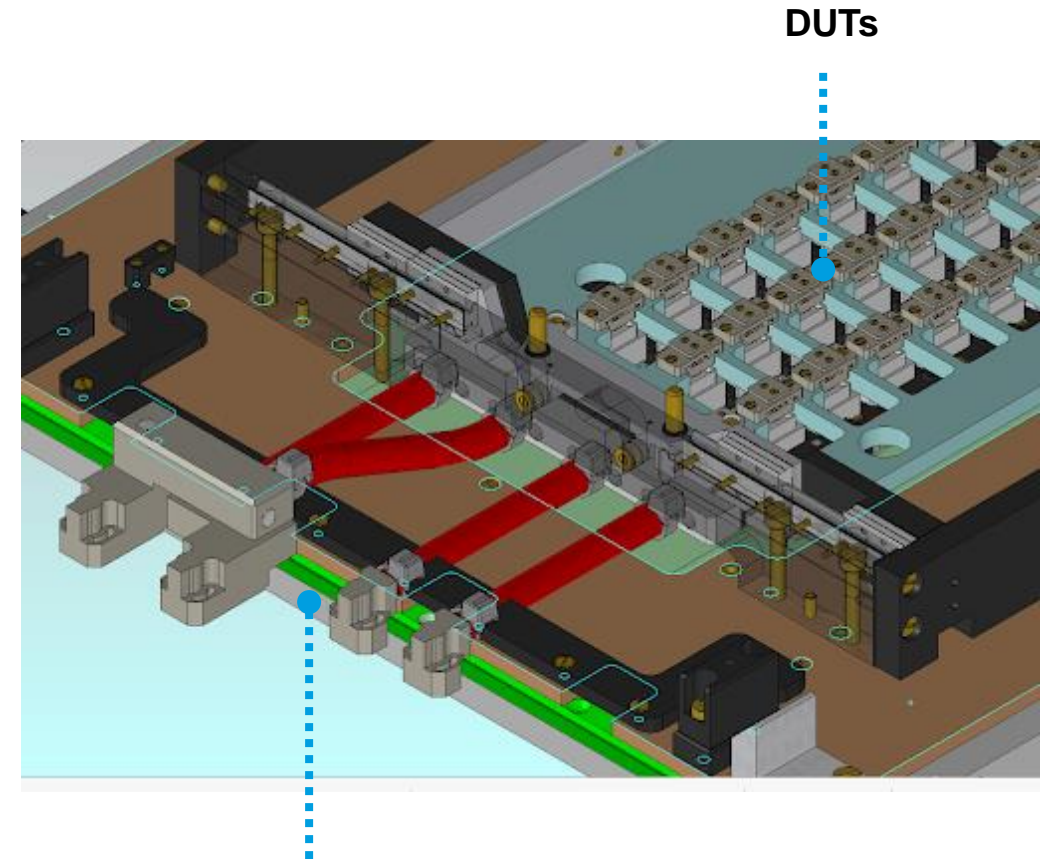


# Case Study 3 Magnetic Sensors



## HIGHLIGHTS

- The test unit can generate **unidirectional, bidirectional or fully tridimensional** magnetic fluxes, according to the test needs
- A **magneto board** can generate the magnetic fields needed to perform the test in correspondence of every DUT, through an electrical coil system and current generators
- The magnetic flux can be static or evolving, according to the **fully programmable AWG** of the current power source
- Chuck, pushers, pogo pins, ceramic pockets and all the hardware around the test area are manufactured in **non-magnetic material to avoid any magnetic field distortion.**

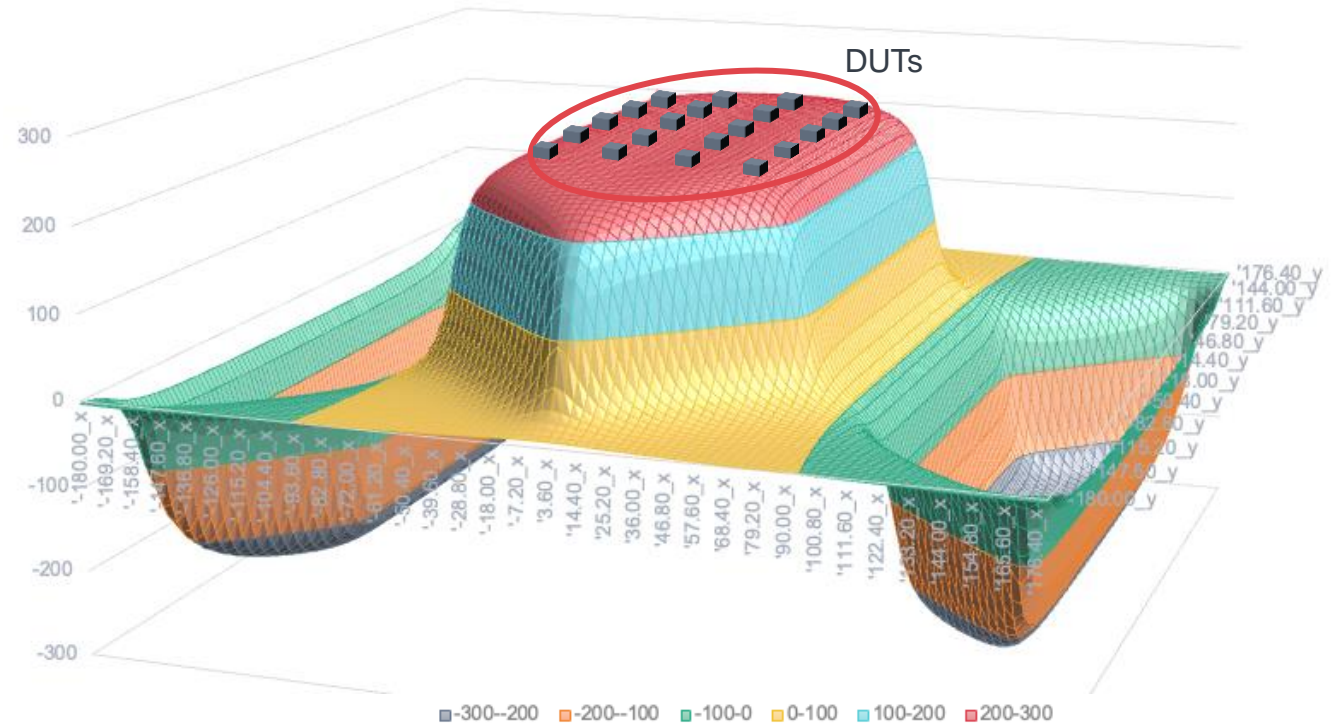
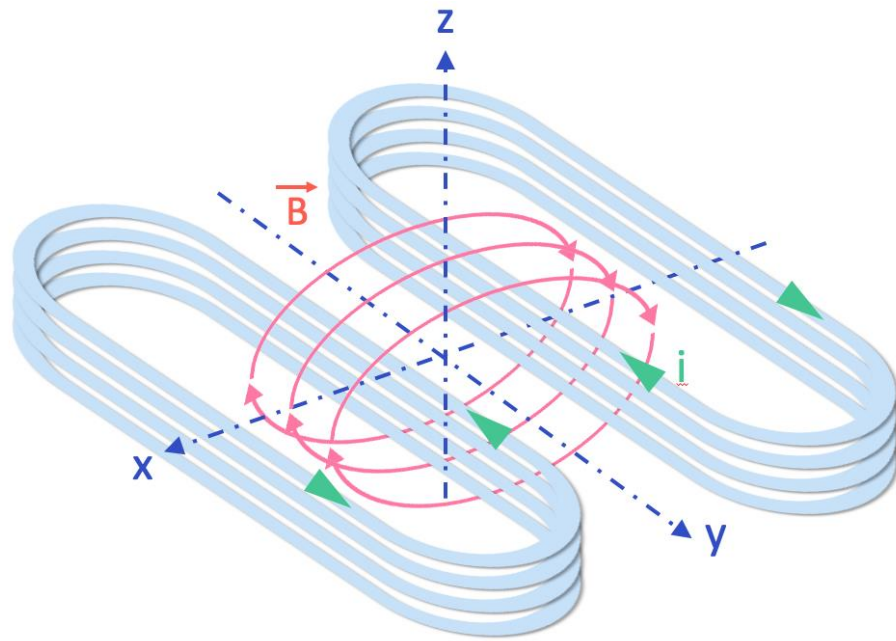


**Magneto board** is located right under the sockets holding the components under test



# Magnetic sensor XY Axes Stimulation

A pair of coreless dipole coils generates a magnetic field, whose lines are almost XY parallel in the region around the axes intersection. The test area is subjected to a uniform magnetic field, stimulating the devices in X and Y.

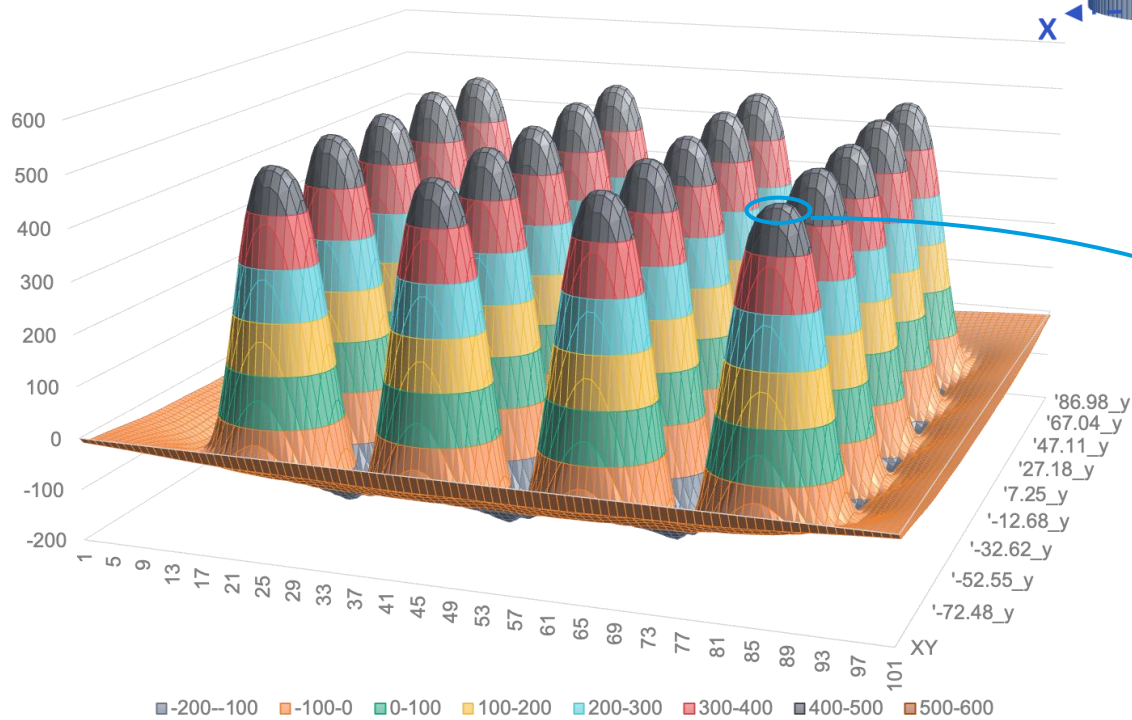
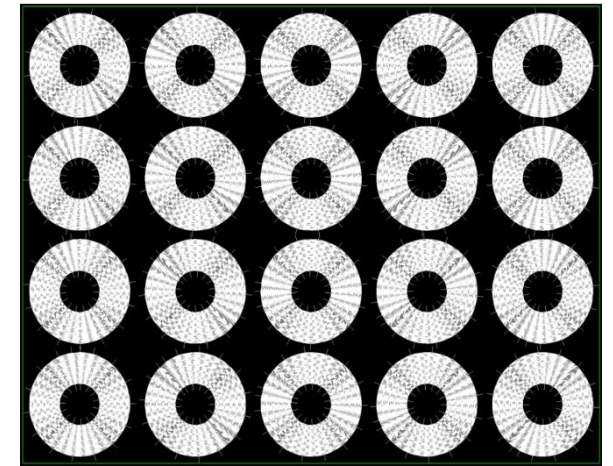
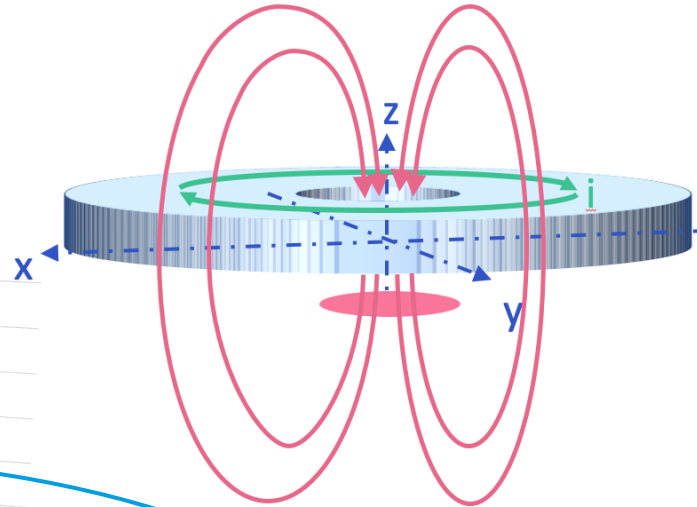




# Magnetic sensor Z Axis Stimulation

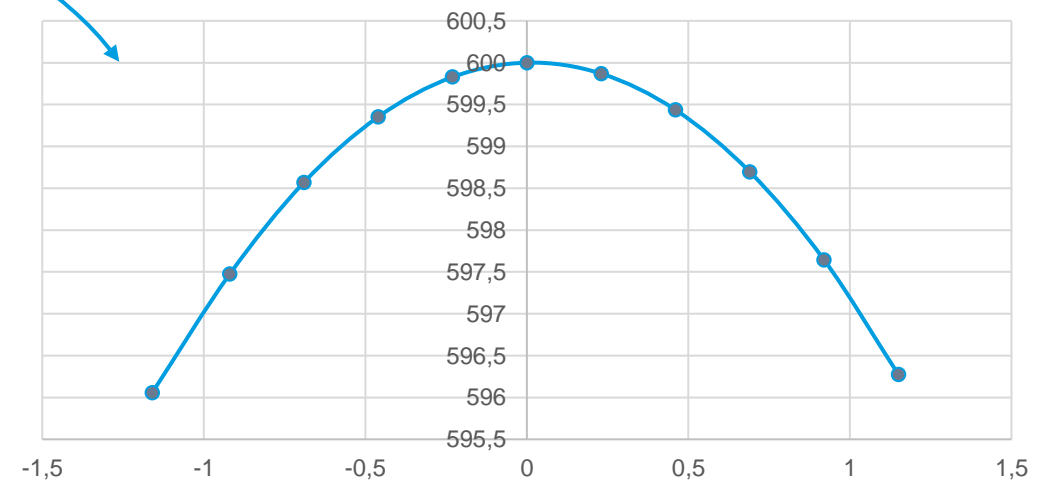


A coreless coil per each site generates a magnetic field whose lines are almost Z parallel in the region close to the axes intersection.



The magnetic field variation is within  $\pm 1\%$  in the Die area

Z Magnetic Flux Flatness within +/- 1mm along X or Y direction from the nominal DUT position





# Conclusions

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Standardizing MEMS testing equipment is crucial for:

- **Addressing manufacturing complexity** → Simplifies production processes, and reduces redundancies
- **Ensuring reliability** → Especially critical for applications like automotive, healthcare, industrial
- **Reducing costs** → Scalable and flexible setups optimize ROI

By embracing standardization and innovation, it is possible to create a MEMS testing ecosystem that is faster, more reliable, and ready to face the challenges of the future.

# THANK YOU!

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